Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	16379	amorph$5 same (PVD physical adj vapor adj deposit$3 sputter$3)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/18 14:05
L2	895	1 and silicide with amorph$5	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/18 14:07
L3	431	2 and (anneal$3 heat$3) with silicide	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/18 14:12
L5	47	3 and (inert argon helium xenon) with amorph$6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/18 14:58
L8	52	(sputter$3 bombard$3) near5 (inert argon helium xenon) near5 (ion$1 atom$1 neutral) with amorph$6	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/18 14:59